



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
(Case No. 211.001-D4-US)

In the Application of: **Fazan et al.**

) Group Art Unit:

Serial No: **10/727,742**

) Before Examiner

Filed: **December 4, 2003**

)

Title: **Semiconductor Device**

)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on March 12, 2004

Date

Michiko Steinberg
(person signing this certificate)

Michiko Steinberg
Signature

FIRST INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Submitted herewith are twenty-three (23) sheets of a modified Form PTO-1449.

The documents listed on the modified Form PTO-1449 were provided or cited during the prosecution of parent applications of the above-captioned application are not enclosed herewith. (See 37 C.F.R. §1.98(d) and MPEP 609). Should the Examiner desire an additional copy of the documents previously provided or cited during the prosecution of parent applications, kindly contact the undersigned.

It is respectfully requested that the Examiner make his/her consideration of these references formally of record with the initial Office Action.

Respectfully submitted,

Neil A. Steinberg
Reg. No. 34,735
650-968-8079

Date: March 12, 2004



Sheet 1 of 23

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT	ATTY. DOCKET NO. 211.001-D4-US	SERIAL NUMBER 10/727,742
	APPLICANT(S) Fazan et al.	
	FILING DATE December 4, 2003	GROUP ART UNIT

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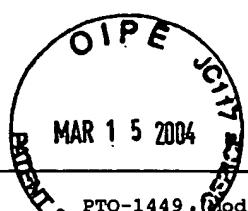
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